



(51) International Patent Classification:  
*B01L 1/04* (2006.01)

(21) International Application Number:  
PCT/US2013/020906

(22) International Filing Date:  
9 January 2013 (09.01.2013)

(25) Filing Language: English

(26) Publication Language: English

(30) Priority Data:  
61/585,951 12 January 2012 (12.01.2012) US

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(81) Designated States (unless otherwise indicated, for every  
kind of national protection available): AE, AG, AL, AM,  
AO, AT, AU, AZ, BA, BB, BG, BH, BN, BR, BW, BY,  
BZ, CA, CH, CL, CN, CO, CR, CU, CZ, DE, DK, DM,  
DO, DZ, EC, EE, EG, ES, FI, GB, GD, GE, GH, GM, GT,  
HN, HR, HU, ID, IL, IN, IS, JP, KE, KG, KM, KN, KP,

KR, KZ, LA, LC, LK, LR, LS, LT, LU, LY, MA, MD,  
ME, MG, MK, MN, MW, MX, MY, MZ, NA, NG, NI,  
NO, NZ, OM, PA, PE, PG, PH, PL, PT, QA, RO, RS, RU,  
RW, SC, SD, SE, SG, SK, SL, SM, ST, SV, SY, TH, TJ,  
TM, TN, TR, TT, TZ, UA, UG, US, UZ, VC, VN, ZA,  
ZM, ZW.

(84) Designated States (unless otherwise indicated, for every  
kind of regional protection available): ARIPO (BW, GH,  
GM, KE, LR, LS, MW, MZ, NA, RW, SD, SL, SZ, TZ,  
UG, ZM, ZW), Eurasian (AM, AZ, BY, KG, KZ, RU, TJ,  
TM), European (AL, AT, BE, BG, CH, CY, CZ, DE, DK,  
EE, ES, FI, FR, GB, GR, HR, HU, IE, IS, IT, LT, LU, LV,  
MC, MK, MT, NL, NO, PL, PT, RO, RS, SE, SI, SK, SM,  
TR), OAPI (BF, BJ, CF, CG, CI, CM, GA, GN, GQ, GW,  
ML, MR, NE, SN, TD, TG).

**Declarations under Rule 4.17:**

- as to the identity of the inventor (Rule 4.17(i))
- of inventorship (Rule 4.17(iv))

**Published:**

- with international search report (Art. 21(3))

(88) Date of publication of the international search report:  
22 January 2015

(54) Title: RETROFITTING CLEANROOM FABRICATORS INTO CLEANSPACE FABRICATORS

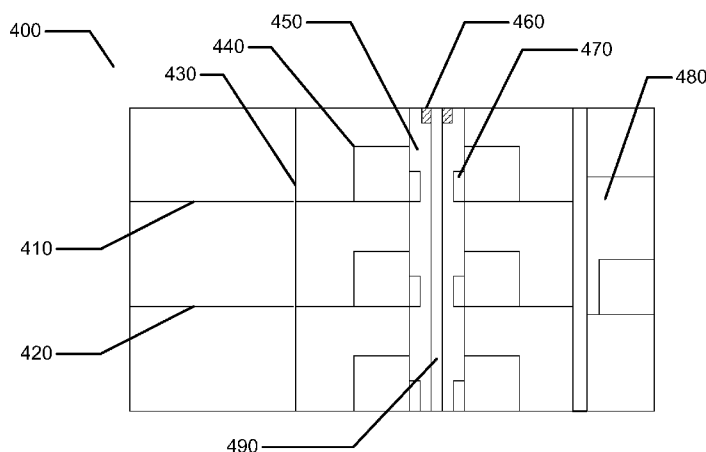


FIG. 4

(57) Abstract: The present invention provides various methods for forming cleanspace fabricators by retrofitting a structure of an existing cleanroom based fabricator. In some embodiments, a cleanspace fabricator is formed within a region of a cleanroom fabricator which is not transformed.